

A Purcell-enabled monolayer semiconductor free-space optical modulator

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Dephasing and non-radiative decay processes limit the performance of a wide variety of quantum devices at room temperature. Here we illustrate a general pathway to notably reduce the detrimental impact of these undesired effects through photonic design of the device electrodes. Our design facilitates a large Purcell enhancement that speeds up competing, desired radiative decay while also enabling convenient electrical gating and charge injection functions. We demonstrate the concept with a free-space optical modulator based on an atomically thin semiconductor. By engineering the plasmonic response of a nanopatterned silver gate pad, we successfully enhance the radiative decay rate of excitons in a tungsten disulfide monolayer by one order of magnitude to create record-high modulation efficiencies for this class of materials at room temperature. We experimentally observe a 10% reflectance change as well as 3 dB signal modulation, corresponding to a 20-fold enhancement compared with modulation using a suspended monolayer in vacuum. We also illustrate how dynamic control of light fields can be achieved with designer surface patterns. This research highlights the benefits of applying radiative decay engineering as a powerful tool in creating high-performance devices that complements substantial efforts to improve the quality of materials.

Transition metal dichalcogenide (TMDC) monolayers display an impressive set of electronic and optical properties. Most notably, they can serve as direct band gap emitters^{1,2} that can offer high quantum yields³ and a broad tunability of the sheet conductivity⁴. For these reasons, they are now actively explored as a new materials platform for next-generation low-dimensional electronics⁵ and optoelectronics^{6,7}, and provide an exciting playground to study quantum and correlated electron physics⁸. For nanophotonic applications, the very strong and tunable light–matter interaction enabled by excitons is particularly attractive^{9–13}. In contrast to many bulk semiconductors and even quantum wells, excitons in TMDC monolayers survive at room temperature as a reduced dielectric screening, and enhanced quantum

confinement in these atomically thin layers yield exciton binding energies as high as a few hundreds of millielectron volts¹⁴. The large electrical tunability of exciton resonances¹⁵ comes with an exciting prospect to efficiently modulate¹⁶ and dynamically control light fields with low switching energies^{17,18}. Such dynamic control can find a wide range of emerging applications, including free-space optical communications¹⁹, optical phased arrays²⁰, image processing²¹ and optical neural networks²². These applications are hard to achieve in compact devices that employ conventional semiconductors and noble metals, as they only exhibit weak electro-refractive and electro-absorptive effects^{23,24}. Two-dimensional (2D) semiconductors therefore seem very promising, but unfortunately their exciton resonances do severely weaken and

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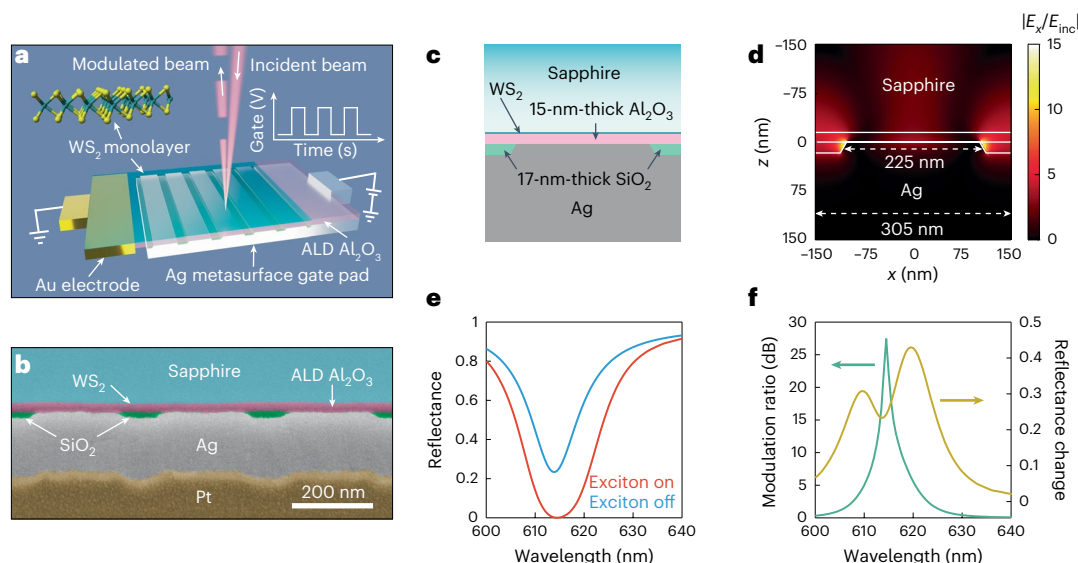


Fig. 1 | Monolayer WS₂ free-space optical modulator. **a**, Schematic of a monolayer WS₂ free-space optical modulator based on a MOS capacitor configuration. The intensity of the reflected beam is modulated by varying the gate voltage between the gold electrode and the silver metasurface gate pad. **b**, Cross-sectional scanning electron microscope (SEM) image of the fabricated optical modulator. A false-colour overlay is used to enhance the contrast between different layers in the device. Scale bar, 200 nm. **c, d**, Detailed cross-sectional geometry (**c**) and the simulated corresponding electric field distribution (**d**) of the designed optical modulator in one period under transverse-magnetic-polarized normal illumination. E_x is the simulated electric field in x direction, and

E_{inc} is the amplitude of the incident field. The incident wavelength is 615 nm. **e**, Simulated reflection spectra of the designed optical modulator under transverse-magnetic-polarized illumination at normal incidence. The exciton resonance in the WS₂ monolayer is switched on (red) and off (blue) artificially by first separating the exciton resonance contribution from the dielectric background in the dielectric function of the WS₂ monolayer and then keeping (on-state) or removing (off-state) this contribution in the dielectric function. **f**, Extracted modulation ratio (green) and absolute reflectance change (yellow) of the designed optical modulator from the simulations in **e**.

broaden with increasing temperature and it is a huge challenge to find ways to harness them effectively at room temperature.

The reported near-unity reflection modulation with TMDC monolayers at cryogenic temperatures^{25,26} essentially disappears at room temperature, and only a reflection modulation of ~0.5% has been achieved so far¹⁷. This occurs because the non-radiative decay and dephasing rates of excitons increase to a value that is about one order of magnitude larger than their intrinsic radiative decay rates in vacuum at ~300 K (refs. 26–29). Challenges with non-radiative decay and dephasing are common to a wide range of quantum materials and they preclude their use in devices operating at room temperature. Researchers usually attempt to limit these undesired processes by improving the materials' quality, but photonic engineering brings an equally powerful route to overcome this challenge. For example, in plasmonics it is well-established that deep-subwavelength-sized metal nanoparticles are plagued by very low scattering efficiencies. This is because the ratio of the radiative and non-radiative decay rates for their surface plasmon excitations is similar in magnitude to those seen in TMDC monolayers at room temperature^{26,30}. Here, superradiance effects were successfully engineered to enhance their scattering intensities^{31,32}. It was also recently suggested that radiative decay engineering can resolve issues with dephasing of quantum emitters^{33,34}. Now we show that 2D semiconductors can be used effectively to electro-optically modulate light waves at room temperature by speeding up their radiative decay³⁵. We place WS₂ monolayers on nanostructured metallic substrates that support surface plasmon excitations capable of enhancing the radiative decay rate of coherently excited excitons via the Purcell effect by one order of magnitude. These photonic substrates can perform a dual function as a low-quality factor (Q) cavity and a high-conductivity gate pad for low-power, solid-state electrical tuning of the excitonic resonance. We further demonstrate dynamic light-field control by adopting a different metasurface gate pad design to electrically modulate the intensity of a steered optical beam.

Results

Concept of a monolayer WS₂ free-space optical modulator

Figure 1a shows a schematic of the designed monolayer tungsten disulfide (WS₂) free-space optical modulator. A piece of WS₂ monolayer is electrically connected to a gold electrode and placed on top of a nanopatterned silver gate pad spaced by a 15-nm-thick Al₂O₃ gate oxide, forming a metal–oxide–semiconductor (MOS) capacitor. The topography of the silver gate pad is defined by a 17-nm-thick SiO₂ nano-strip array with a period (p) of 305 nm (Fig. 1b). The detailed cross-sectional geometry for one period of the designed modulator is displayed in Fig. 1c. To analyse its behaviour in optical simulations, we first perform ellipsometry to quantify the optical properties of the various materials in the device (see Methods). By using ellipsometric data for WS₂, it is assumed that this material can be treated as spatially uniform and that its optical behaviour can be modelled with a linear, coherent response. This is a frequently made assumption that can provide many valuable insights, although it tacitly assumes that the exciton broadening can fully be ascribed to non-radiative decay. For an illumination wavelength of 615 nm, we can see that the simulated electric field near the metal surface is greatly enhanced (Fig. 1d) and this is key to achieving efficient optical modulation. The situation is very different from a conventional MOS configuration with planar metallic gate pads. Such gate pads display severely weakened electric fields near their surface due to the approximately π reflection phase pickup for incident light waves (Supplementary Fig. 1). To electrically modulate the device, we capitalize on the demonstrated possibility to fully switch exciton resonances in a WS₂ monolayer on and off by charge injection^{9,15,17}. Under the assumption that this can also be accomplished in our device (Supplementary Fig. 2), we quantify the achievable modulation from wave-optics simulations (Fig. 1e). A more than 25 dB modulation ratio and a 40% reflectance change are observed in the simulation upon switching of the exciton resonance (Fig. 1f). The nanopatterned gate pad thus provides a large boost in the reflection modulation by almost two orders of magnitude

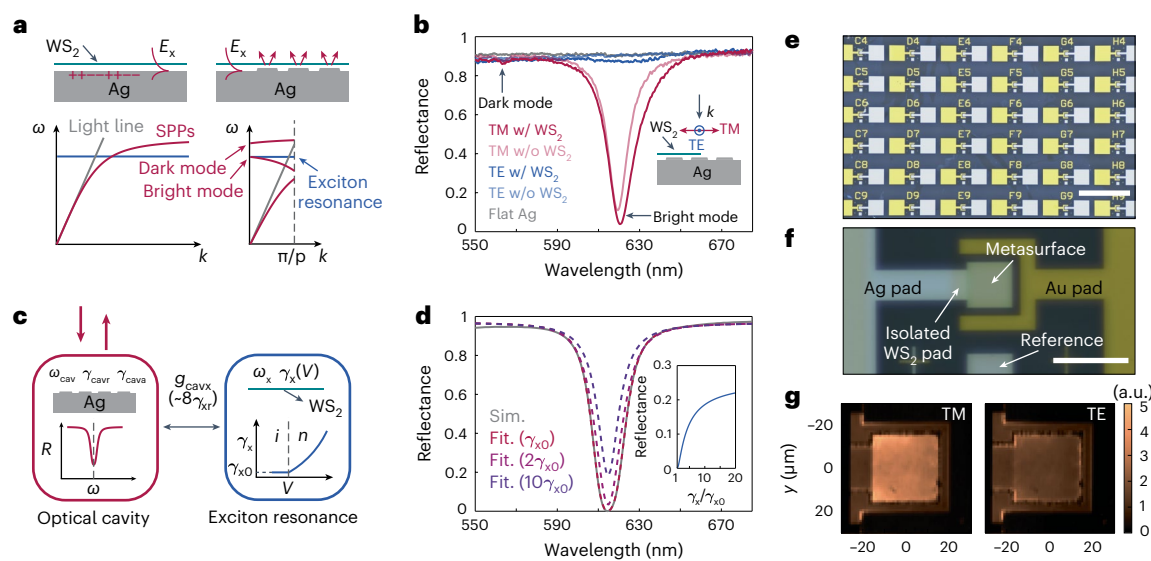


Fig. 2 | Enhanced modulation with a silver metasurface gate pad. a, Realization of a quasi-guided SPP mode supported by the metasurface gate pad following the introduction of a periodic perturbation to the top surface of the silver gate pad. Red curves represent the modal dispersion of the (perturbed) SPPs at the silver/dielectric interface, and grey lines refer to the light lines in the dielectric. Two optical modes are found at the Γ -point near the exciton resonant frequency supported by the silver metasurface gate pad. **b,** Measured reflection spectra of fabricated optical modulators under transverse-magnetic (TM) polarized (red) and transverse-electric (TE) polarized (blue) normal illumination. Solid and semi-transparent curves represent the reflection spectra for the devices with and without WS₂ monolayers, respectively. The grey curve indicates the reflection spectrum of the flat silver gate pad. **c,** Mechanism of the

enhanced intensity modulation of the reflected beam. A one-port, two-coupled cavity system is used to describe the essential physics of the optical modulator. The total decay rate of the excitons in WS₂ can be tuned via electrical gating. **d,** Fitted (dashed red) and simulated (grey) reflection spectra of the designed optical modulator. The calculated reflection spectra with different decay rates of the excitons in WS₂ are also shown in different coloured dashed curves. The inset shows the calculated reflectance at the exciton resonant wavelength as a function of the decay rate of excitons. **e,** Optical image (taken from the top gate pad side) of the fabricated optical modulator array. Scale bar, 500 μm . **f,** Optical image (taken from the substrate side) of one fabricated optical modulator in the array. Scale bar, 50 μm . **g,** Polarization-resolved photoluminescence map of the fabricated optical modulator.

compared with the modulation using a suspended WS₂ monolayer ($\sim 0.5\%$ modulation; Supplementary Fig. 3).

Enhancing the radiative decay of excitons with a metasurface

The nanopatterned metal surface can improve the modulator's performance by enhancing both the excitation field and radiative decay for the excitons in the WS₂ monolayer via the Purcell effect. Purcell demonstrated that the radiative decay rate of emitters can be increased by placing them in an optical cavity³⁶. To understand the increased modulation for our structure in more detail, it is important to realize that the grooves patterned in our gate pad facilitate the excitation of several optical resonances capable of concentrating the in-plane electric fields within the WS₂ monolayer. First, normally incident light can excite guided resonances for surface plasmon polaritons (SPPs) on the periodically nanopatterned metal surface. This possibility emerges as the periodic perturbation can fold the dispersion curve of the SPPs into the first Brillouin zone (Fig. 2a)³⁷. We choose a 305 nm period to couple the incident 615 nm light. By doing so, two optical modes (one bright, one dark) can be found at the Γ -point near the exciton resonant frequency. Figure 2b shows the measured reflection spectra of a fabricated modulator with the patterned gate pad. The efficient excitation of the bright optical mode from the lower photonic band produces a large reflection dip around 620 nm. A second, small dip is also observed in the reflection spectrum around 565 nm, corresponding to the symmetry-protected dark mode (that is, a bound state in the continuum) from the upper photonic band (Supplementary Fig. 4).

As SPPs are longitudinal electron-density waves, they can only be excited under transverse magnetic polarized illumination, where the electric field is normal to the length of the grooves. Meanwhile, the exciton resonance can be probed in the reflection spectrum under

transverse electric polarized illumination (Supplementary Fig. 5), where it is not overpowered by the SPP modes. It is clear that the exciton resonance is spectrally well-aligned with the bright optical mode supported by the nanopatterned gate pad. Upon excitation of the combined system, the WS₂ monolayer can resonantly absorb and then coherently re-emit the light back into the coupled SPP mode with a notably increased excitation and radiative decay rate for the excitons due to the concentrated vacuum field as well as the boosted local density of optical states. At the same time, the periodically patterned gate pad can ultimately decouple the excited SPPs from the surface back into free space. At this point it is important to note that the period of the perturbation on the metal gate pad is sufficiently small that emitted and decoupled light cannot decay into diffracted orders. As such, it is appropriate to term the patterned gate pad a metasurface. For the metasurface, strong interference effects are expected between the radiating SPPs that are coupled to the WS₂ monolayer and the non-resonant background produced by a direct reflection from the metal surface. Active manipulation of this interference can be leveraged to achieve dynamic reflection modulation.

Figure 2c graphically illustrates how the intensity of the reflected beam can be modified via carrier injection into the WS₂ monolayer through the optical coupling between the coherently excited excitons and the above-analysed bright quasi-guided SPP mode supported by the metasurface. In the absence of the optical coupling, the total decay rate of excitons for a neutralized sample ($\hbar\gamma_{x0}$) is ~ 28.9 meV, extracted from the simulations based on the optical constants measured via ellipsometry (Supplementary Fig. 6). These very large decay rates are quite typical for TMDCs at room temperature and come with substantially broadened exciton resonances that are incapable of achieving efficient modulation²⁶. The resonances broaden even further with

electrical gating (V) as additionally injected electrons notably shorten the exciton lifetime³⁸. Despite the broadening, our metasurface gate pad can help achieve good modulation. To understand this, we first develop an optical rate-equation model to quantitatively link the reduction in the exciton lifetime to the applied electrical bias (Supplementary Note 1). We then explain the optical behaviour of our device under transverse-magnetic-polarized illumination by developing a temporal coupled mode theory (CMT)³⁹ for two-coupled cavities with one port (Supplementary Note 2). The metasurface serves as one of these cavities and the resonant excitonic system serves as the second cavity. As the full-wave simulations, the CMT assumes a linear, coherent response for our materials. We find that the predicted reflection spectrum modulation obtained from CMT is consistent with our wave-optics simulations (Figs. 1e and 2d). By fitting the CMT to the simulation data, we can extract key modelling parameters that capture the behaviour of our system. We find that we can ignore the direct radiative decay channel of excitons into free space ($\hbar\gamma_{\text{fr}} \approx 2.3$ meV) as their optical coupling to the SPP mode ($\hbar g_{\text{cavx}} \approx 17.7$ meV) is found to be around eight-times faster (Supplementary Fig. 6). The optical properties of the metasurface cavity can be designed at will and are described by its resonant wavelength ($2\pi c/\omega_{\text{cav}} \approx 615$ nm), radiative decay rate ($\hbar\gamma_{\text{cavr}} \approx 14.4$ meV) and non-radiative decay rate ($\hbar\gamma_{\text{cava}} \approx 4.9$ meV) for the chosen metasurface geometry used in the simulation (Fig. 1e,f). The exciton resonant frequency (ω_x) is also to some degree tunable through band gap engineering⁴⁰. The CMT produces the following expression for the gate-dependent reflectance of the modulator:

$$R(\omega, V) \cong \left| -1 + \frac{2\gamma_{\text{cavr}}}{i(\omega - \omega_{\text{cav}}) + \gamma_{\text{cavr}} + \gamma_{\text{cava}} + \frac{(g_{\text{cavx}})^2}{i(\omega - \omega_x) + \gamma_x(V)}} \right|^2. \quad (1)$$

The importance of the electrically tunable term $(g_{\text{cavx}})^2/(i(\omega - \omega_x) + \gamma_x(V))$ is determined by the strength of the direct coupling between the metasurface cavity mode and exciton resonance g_{cavx} as well as the exciton resonance frequency ω_x and bias-dependent exciton decay rate $\gamma_x(V)$. This term captures the ability of the SPPs to store energy in the exciton resonance and retrieve it. To see how this term can boost the modulation efficiency, it is of value to explore the case in which the metasurface cavity is on resonance ($\omega = \omega_{\text{cav}}$). Here, the expression for the reflectance can be simplified to:

$$R(V) \cong \left| -1 + \frac{2\eta_{\text{cav}}}{1 + \frac{\Gamma}{i\delta_x + \gamma_x(V)}} \right|^2, \quad (2)$$

where $\eta_{\text{cav}} = \gamma_{\text{cavr}}/(\gamma_{\text{cavr}} + \gamma_{\text{cava}})$ determines the scattering efficiency of the metasurface cavity, and $\delta_x = \omega_{\text{cav}} - \omega_x$ is the detuning for the coupled system; $\Gamma = g_{\text{cavx}}^2/(\gamma_{\text{cavr}} + \gamma_{\text{cava}})$ quantifies the Purcell-enhanced excitation and radiative decay rate of excitons from and back into the quasi-guided SPP mode of the metasurface cavity. The calculated time evolution of the coupled system confirms the accelerated decay process for the excitons via the Purcell effect (Supplementary Fig. 7). When the excitons are switched off ($\gamma_x \approx \infty$), the reflectance is simply determined by the scattering efficiency of the metasurface cavity $R_{\text{max}} = |2\eta_{\text{cav}} - 1|^2$, and the near-unity reflection can be achieved if the metasurface is lossless. To maximize the modulation ratio, we need to operate the modulator near the critical coupling point ($R_{\text{min}} = 0$) when the exciton is switched on, leading to the relation $2\eta_{\text{cav}} - 1 = \frac{\Gamma}{i\delta_x + \gamma_{x0}}$. It is

thus clear that the enhanced coupling of the quasi-guided SPP mode with the excitons in the WS₂ monolayer enables the achievement of critical coupling. We highlight that the modulation $\left(\Delta R \approx \left| \frac{\Gamma}{i\delta_x + \gamma_{x0}} \right|^2\right)$ can be efficient only if the Purcell-enhanced radiative decay rate

($\hbar\Gamma \approx 16.2$ meV) becomes comparable with the sum rate of other unwanted decay processes ($\sim \hbar\gamma_{x0} \approx 28.9$ meV), and the exciton resonance is degenerate with the quasi-guided SPP mode ($\delta_x \approx 0$). At this point, it is worth noting that the enhanced radiative decay rate provided by the metasurface would also be beneficial if some of the excitonic broadening at room temperatures had been due to dephasing processes. Although this project is focused on maximizing the modulator performance, it is interesting to note that other valuable operating regimes, such as strong coupling, can be achieved in the same configuration as well (Supplementary Fig. 8).

Efficient intensity modulation of free-space light beams

To further demonstrate our platform and design concept, we fabricate optical modulators starting from a millimetre-scale single crystal monolayer WS₂ flake exfoliated from bulk crystal⁴¹ onto a sapphire substrate (Supplementary Fig. 9). This allows us to pattern a device array consisting of 150 optical modulators on a 1 cm² chip using standard cleanroom processing (Fig. 2e). An optical image (taken from the substrate side) of one fabricated optical modulator in the array highlights the details of the configuration (Fig. 2f). A 50 × 50 μm² isolated WS₂ monolayer pad is electrically connected to a U-shaped gold electrode, and a 30-μm-sized silver metasurface gate pad is fabricated in the centre, spaced by a 15-nm-thick Al₂O₃ film that serves as the gate insulator. The measured polarization-resolved photoluminescence map (Fig. 2g; see also Supplementary Fig. 10 for detailed photoluminescence spectra in the maps) confirms the exciton-plasmon performance of the silver metasurface gate pad, where the exciton emission is enhanced by a factor of ~2 for the transverse-magnetic polarization that supports SPPs (see Supplementary Fig. 11 for simulations of the Purcell-enhanced photoluminescence).

We note that the resonant wavelength of the SPP mode can be tuned systematically by gradually changing the periodicity of the perturbation (Fig. 3a). This is particularly important for maximizing the modulation effect, as the optical mode supported by the silver metasurface pad needs to be degenerate with the exciton resonance. For a fabricated modulator with the optimal periodicity, we measure the changes in the reflection spectrum from a 10 × 10 μm² device area using a fibre-coupled confocal microscope as a function of the gating voltage, which was applied from -3 V to 3 V in 3 V steps (Fig. 3b). We also need to apply hole injection here to bring the WS₂ monolayer as closely back to its neutral state as possible, as exfoliated TMDC monolayers are usually found to be n-doped due to chalcogen vacancies as well as extrinsic doping from charges on the substrate and electron-beam exposure (Supplementary Fig. 12)^{42,43}. We find that the modulator operates very close to the critical coupling condition when the WS₂ monolayer is neutralized at -3 V, and gradually deviates from it by electron doping. A 3 dB modulation ratio (at 627 nm), as well as a 10% reflectance change (at 621 nm), are experimentally demonstrated as shown in Fig. 3c. This absolute reflectance change is 20-times larger than our previous ionic-liquid gating experiment in the absence of the optical coupling¹⁷, and is quite comparable to a recent low-temperature solid-state back-gating experiment at 4 K with hexagonal boron nitride encapsulation²⁷. All of these features are in good agreement with the simulated results shown in Fig. 1e,f, except that the modulation is weaker in the experiment. We attribute this to the weaker exciton resonance oscillator strength in the WS₂ monolayer caused by the additional defect generation⁴⁴ and inhomogeneous broadening due to the dielectric and charge disorder in the atomic layer deposition (ALD)-deposited Al₂O₃ encapsulation (Supplementary Fig. 13). Furthermore, the insubstantial carrier injection limited by a very thin, non-uniform gate insulator restricts the exciton lifetime modulation range⁴⁵ (Supplementary Note 3).

We also perform photoluminescence spectrum modulation (Supplementary Fig. 14) and lifetime modulation (Supplementary Fig. 15) measurements to study the exciton dynamics and to verify the role

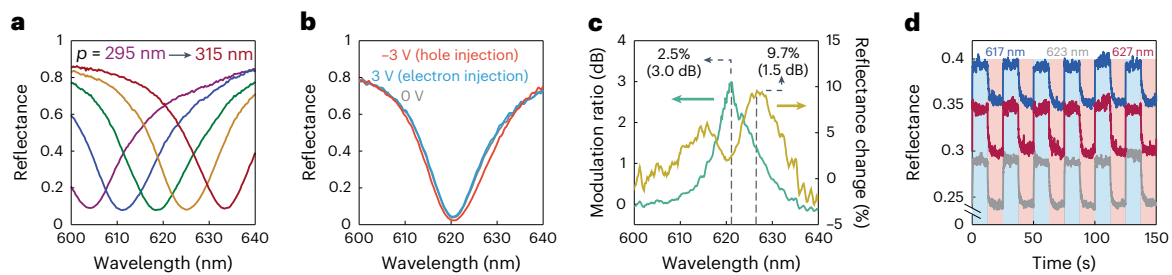


Fig. 3 | Intensity modulation of the reflected beam via electrical gating.

a, Measured reflection spectra of a series of fabricated optical modulators with the perturbation periodicity changing from 295 nm (purple) to 315 nm (maroon) in 5 nm steps. **b**, Measured reflection spectrum modulation of a fabricated optical modulator in the device array ($p = 305$ nm). The gating voltage is applied from -3 V (hole injection, red) to 3 V (electron injection, blue) in 3 V steps. This optical modulator has the optimal perturbation periodicity to spectrally match the quasi-guided SPP mode with the exciton resonance almost perfectly. **c**, Extracted

modulation ratio (green) and absolute reflectance change (yellow) spectra from the measurements in **b**. A 3 dB modulation ratio and a 10% reflectance change are observed in the experiment. **d**, Measured alternating current modulation of the reflected beam from the fabricated optical modulator. Different coloured curves indicate focused supercontinuum laser illumination with different centre wavelengths. The shadings represent the gating voltage applied, cycled between 3 V (blue) and -3 V (red). All of the spectra in **a–d** are collected under transverse-magnetic-polarized normal illumination.

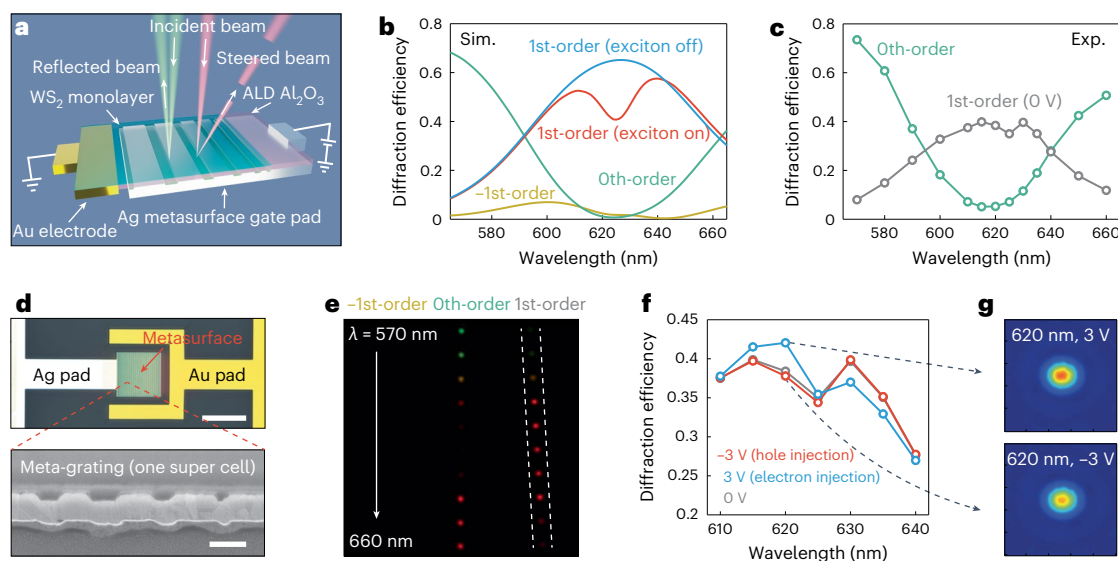


Fig. 4 | Monolayer WS₂ light-field modulators with a beam-steering function.

a, Schematic of a monolayer WS₂ light-field modulator with a beam-steering function. The periodic perturbation is replaced by super cells that can provide a 2π phase gradient across one cell. **b,c**, Simulated (**b**) and measured (**c**) diffraction efficiency spectra of the light-field modulator under transverse-magnetic-polarized normal illumination. The first-order diffraction is maximized around the exciton resonance wavelength, whereas the zeroth- and negative-first-order diffraction are suppressed. **d**, Optical (top) and cross-sectional SEM (bottom)

images of the fabricated light-field modulator. Scale bars, 30 μ m (top); 200 nm (bottom). **e**, Optical images of the back-focal plane of the fabricated light-field modulator. The incident wavelength is tuned from 570 nm to 660 nm in steps of 10 nm. **f**, Measured intensity modulation of the first-order diffracted beam via electrical gating. The gating voltage is applied from -3 V (hole injection, orange) to 3 V (electron injection, blue) in 3 V steps. The incident wavelength is tuned from 610 nm to 640 nm in 5 nm steps. **g**, Optical images of the modulated first-order diffracted beam with an incident wavelength of 620 nm.

of carrier injection in the optical modulation^{38,42,46}. An alternating current modulation experiment is further conducted by measuring the real-time reflected beam intensity with a focused narrow-band illumination (NA = 0.2, FWHM \approx 5 nm), as shown in Fig. 3d. We find that the focused beam spectrally averages the modulation effect, as a quasi-constant (\sim 5%) reflectance modulation is achieved in a \sim 15 nm bandwidth (Supplementary Fig. 16), revealing the possibility to modulate beams in a certain bandwidth as well. We also confirm the good reversibility of the fabricated optical modulator. The observed modulation speed is mainly limited by the large resistor-capacitor time constant of the circuit for electrical gating due to the substantial contact and access resistance between the gold electrode and the modulated WS₂ monolayer (Supplementary Fig. 17), which can be improved by proper contact engineering and device configuration optimization^{44,47}. We note that in principle a gigahertz-speed modulation

in such a solid-state gating device is possible and has been reported in similar configurations⁴⁸.

Achieving dynamic control over light fields

Finally, we extend the concept from the reflection modulation to a more general dynamic control over light fields. As a proof of concept, we demonstrate a monolayer WS₂ light-field modulator with a beam-steering function, where a silver metasurface with a constant phase gradient serves as the gate pad, and the intensity of the first-order diffracted beam is electrically modulated (Fig. 4a). In principle, the 2π full-phase control needed for a gradient metasurface can be achieved in the over-coupling regime by varying the filling fraction of the grooves (Supplementary Fig. 18)⁴⁹. We subsequently conduct a global optimization to take into account the coupling between neighbouring grooves due to the propagating SPPs. Figure 4b shows the simulated diffraction

efficiency spectra of the optimized monolayer WS₂ light-field modulator. It is designed so that the first-order diffraction dominates the zeroth-order specular beam near the exciton resonant wavelength. The redirected beam can efficiently be modulated by controlling the intensity of the exciton resonance of the WS₂ monolayer. We again systematically pattern a light-field modulator array on a 1 cm² fused silica chip as shown in Fig. 4d. The measured diffraction efficiency spectra of a fabricated light-field modulator match the simulated results very well (Fig. 4c). The efficient beam steering is also visualized by a series of optical images of the modulator that are taken in the Fourier plane with the incident wavelength range adjusted from 570 nm to 660 nm in 10 nm steps (Fig. 4e). We conduct the modulation experiment by measuring the intensity change of the first-order diffracted beam via electrical gating as a function of the incident wavelength (Fig. 4f). A clear modulation is observed near the exciton resonant wavelength, reaching its maximum at 620 nm with a ~5% change in its diffraction efficiency (0.5 dB modulation ratio). The observed asymmetric line-shape in the modulation may result from the trion resonance which is not considered in the simulations⁴². Such a modulation can be easily recognized from the optical images of the first-order diffracted beam with different gating voltages (Fig. 4g).

Discussion

Altogether, these results demonstrate a novel free-space optical modulator platform that leverages the highly tunable optical properties of a semiconductor monolayer and an optimized photonic environment to boost the exciton–light interaction to achieve effective modulation at room temperature. This platform can lead to various practical applications that require fast modulation of free-space optical signals. At a higher level, this work shows the notable benefits of radiative decay engineering for excitons in 2D semiconductors in the performance of optical modulation that complements significant efforts in improving materials quality.

Online content

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Methods

Numerical simulations

We perform 2D finite-element simulations in the frequency domain using the commercial software package COMSOL (COMSOL, Inc.) to study the optical properties of the designed monolayer WS₂ free-space optical modulator. We apply periodic boundary conditions to simulate the properties of the modulator with periodic perturbations. The same boundary condition is also applied to the entire super cell for the light-field modulator. The modulator is illuminated by a normally incident plane wave and all the possible diffraction orders are added as ports in the simulation. The Purcell enhancement is calculated by placing a linear electric dipole in the WS₂ monolayer plane and calculating the ratio between the power emitted from the dipole in the modulator configuration and in the vacuum. Perfectly matched layers are added at the boundaries to converge the simulation.

The WS₂ monolayer is modelled as a 0.618-nm-thick dielectric slab¹³ with an in-plane refractive index determined by ellipsometry measurements on a commercially available (2D Semiconductors) chemical-vapour-deposition-grown WS₂ monolayer on a sapphire substrate⁵⁰. The exciton resonance contribution is separated from the dielectric background of the monolayer WS₂ by fitting the dielectric constant from an ellipsometry measurement with two Lorentz oscillators for the A and B excitons and a Tauc–Lorentz oscillator for the inter-band transitions. The out-of-plane refractive index of WS₂ monolayer is artificially set as 1. The dispersion of silver is described in a Drude model with a constant dielectric background from the inter-band transitions, in which the plasma frequency and damping constant in the Drude model are fitted to match the observed SPP dispersion. The refractive index of Al₂O₃ by ALD and SiO₂ by electron-beam evaporation is set as 1.67 and 1.48, both determined by ellipsometry measurements. The refractive index of sapphire and fused silica substrate is set as 1.77 and 1.46, respectively.

Device fabrication

Millimetre-scale single crystal WS₂ monolayer exfoliation. WS₂ monolayers are exfoliated from bulk WS₂ crystals (HQ graphene) onto a sapphire or fused silica substrate using gold tape exfoliation⁴¹. For preparation of the gold tape, a 100-nm-thick gold layer is deposited onto a clean silicon wafer (Nova wafers) with an electron-beam evaporator (Kurt J. Lesker). The Au/Si is subsequently spin coated with a layer of polyvinylpyrrolidone (PVP, Fischer) as a sacrificial layer for protection against contamination. A piece of thermal release tape (3196 S, Semiconductor Corp) is pressed onto the PVP/Au layer to peel off the gold surface from the silicon substrate, revealing a clean and flat gold surface templated by the flat silicon wafer. The templated-stripped gold surface is pressed upon a cleaved WS₂ crystal surface to peel a monolayer off the bulk crystal. The thermal release tape/PVP/Au/WS₂ layer is later pressed onto the substrate. After releasing the tape by heating on a hotplate at 95 °C and dissolving the PVP layer in deionized water, the remaining gold is etched away in a homemade KI/I₂ etchant solution, leaving monolayers on the substrate. The remaining etchant and solvent are rinsed with water and isopropyl alcohol, and dried with a N₂ gun.

Nanofabrication of monolayer WS₂ free-space optical modulators.

(1) Gold electrode and marker patterning. We start the fabrication from a millimetre-scale WS₂ monolayer on a 1 cm² sapphire substrate. A 500-nm-thick MMA/180-nm-thick polymethyl methacrylate (PMMA) double-layer is spin coated onto the WS₂ monolayer to serve as a positive-tone electron-beam resist layer. A thin conductive polymer layer (E-Spacer 300Z) is then spin coated to mitigate charging effects during the electron-beam lithography process (JEOL 6300 100 kV system, electron-beam current = 9 nA, dose = 500 μC cm⁻²). The development is performed in a methyl isobutyl ketone:isopropyl alcohol (1:1) solution for 45 s; 100-nm-thick gold is then deposited by electron-beam

evaporation (Kurt J. Lesker), followed by overnight lift-off in acetone. (2) WS₂ monolayer pad isolation. The PMMA/MMA double-layer electron-beam lithography, as described in (1), is conducted again to define the shape of the WS₂ monolayer pad to be isolated. We use a larger electron-beam current (30 nA) to save the writing time for large features. Low-energy (30 W) argon sputtering (Oxford PlasmaPro 80) is conducted to only etch the WS₂ monolayer away, and the remaining resist is removed by rinsing the sample in acetone overnight. (3) Gate oxide deposition. A 1-nm-thick aluminium film is first deposited on the substrate by electron-beam evaporation (AJA) and then oxidized overnight into Al₂O₃ (~2 nm thick) as the seeding layer. A 13-nm-thick Al₂O₃ dielectric layer is then deposited via atomic layer deposition at 200 °C (Cambridge Nanotech Fiji or a home-built tool⁴³). (4) SiO₂ nano-strip patterning. The PMMA/MMA double-layer electron-beam lithography, as described in (1), is conducted again to define the shape of the SiO₂ nano-strip array. To improve the writing resolution for fine structures, a thinner MMA layer (100 nm) is spin coated and we apply a smaller electron-beam current (0.5 nA) during the exposure. A 17-nm-thick SiO₂ layer is then deposited by electron-beam evaporation (AJA), followed by an overnight lift-off in acetone. (5) Silver top gate pad patterning. The PMMA/MMA double-layer electron-beam lithography, as described in (1), is conducted again to define the shape of the silver top gate pad. 180-nm-thick silver is then deposited by electron-beam evaporation (Kurt J. Lesker), followed by a 20-nm-thick platinum deposition in the same tool to protect silver from oxidization. The entire fabrication process is graphically illustrated in Supplementary Fig. 9.

Nanofabrication of monolayer WS₂ light-field modulators. The fabrication process of the monolayer WS₂ light-field modulator is similar to that of the optical modulator described above. The difference is that, first, we start the fabrication from a millimetre-scale WS₂ monolayer exfoliated on a 1 cm² fused silica substrate, and second, 40-nm-thick SiO₂ are deposited in making SiO₂ nano-strips to achieve a larger radiative decay rate for the quasi-guided SPP mode supported by the metasurface gate pad, so that the modulator is operated in the over-coupling regime.

Integration with printed circuit boards for modulation experiment.

To test the optical response of the fabricated modulators with electrical gating, we wire bond the gold electrodes as well as the silver top gate pads to a home-made printed circuit board (PCB) (Supplementary Fig. 19). A hole is drilled on the PCB to allow the reflection measurement with illumination through the substrate.

Optical measurements

Direct current electrical gating. The fabricated optical modulator is electrically gated by a source meter (Keithley 2612), while the gold electrode (WS₂ monolayer) is grounded. The leakage current is monitored when we apply the electrical bias. The maximum gating voltage that we can safely add onto the 15-nm-thick gate oxide was found to be ±3 V, which corresponds to a critical electric field of ~0.2 V nm⁻¹. This number is smaller than the reported breakdown electric field in thick Al₂O₃ (~1 V nm⁻¹). We attribute this to the non-uniformity of the ALD Al₂O₃ deposited on the WS₂ monolayer, as well as the enhanced local electric field due to the sharp edges of the silver metasurface gate pad.

Bright-field reflection measurements. We perform the optical reflection measurement using a Nikon C2 confocal microscope. Unpolarized white light from a halogen lamp is used for top-illumination of the sample through a ×4 objective (Olympus, NA = 0.1). The reflection signal is then collected by the same objective and analysed by a linear polarizer. A confocal scanner with a 40 μm pinhole is used to spatially select the reflection signal (collection area diameter ~10 μm) which is analysed using a SpectraPro 2300i spectrometer and Pixis Si CCD (~70 °C detector temperature). When we conduct the serious measurement on the

modulator with the optimized periodicity, to fully take advantage of the spectral resolution of the spectrometer, the slit width is set as 5 μm , and a blazed grating ($\lambda_b = 500 \text{ nm}$) with a groove density of 300 lines per millimetre is selected. The aperture stop is fully closed to collimate the top illumination as well as possible. The reported spectra are averaged by five frames (160 s integration time each). Meanwhile, a larger slit width (25 μm) and a grating with less groove density (150 lines per millimetre) are used to select the modulator with the optimal periodicity in the device array (Fig. 3a) for faster signal collection (40 s integration time each). All of the reflection spectra are normalized by the reflection spectrum of a protected silver mirror (Thorlabs, PF10-03-P01). The reflection from the top surface of the substrate has been removed through post-data processing, and the spectra shown in the figures have been smoothed using MATLAB.

Spectrally and spatially resolved photoluminescence measurements. We conduct the spectrally and spatially resolved photoluminescence measurement of the WS_2 monolayer in the optical modulator using a Witec confocal Raman imaging microscope. A 532 nm laser is fibre-coupled to the microscope and is tightly focused by a $\times 50$ objective (Nikon, NA = 0.55) to optically pump the WS_2 monolayer. The photoluminescence emission is collected by the same objective, filtered by a dichroic filter cube as well as a long-pass filter (Semrock, LP03-532RU-25), and polarized by a linear polarizer if necessary. A 100- μm -diameter fibre is used as the confocal pinhole and is coupled to a spectrometer to analyse the spectral properties of the photoluminescence emission. The sample (attached on the PCB) is placed on a motorized stage to spatially map the photoluminescence emission with submicrometre resolution.

Time-resolved photoluminescence measurements. We conduct the time-resolved photoluminescence measurement of the WS_2 monolayer in the optical modulator using a second Witec confocal Raman imaging microscope. The photoluminescence excitation and collection process is similar to what is described above, but with a 485 nm pulsed laser (PicoQuant P-C-485, repetition frequency = 40 MHz) and a different $\times 50$ objective (Zeiss, NA = 0.55). A 100- μm -diameter fibre is used as the confocal pinhole and is coupled to an avalanche photodiode (APD; Micro Photon Devices) to measure the lifetime of excitons by time-correlated single-photon counting.

Reflection measurements with alternating current modulation. We perform the optical reflection measurement with alternating current electrical modulation using the second Witec confocal Raman imaging microscope as described above. A supercontinuum laser and an acousto-optic tunable filter (Fianium) are used to generate and tune the wavelength of the laser beam ($\sim 5 \text{ nm}$ bandwidth). The laser is fibre-coupled to the microscope and focused on the sample by a $\times 10$ objective (Zeiss, NA = 0.2). The reflection signal is then collected by the same objective and detected in real time by the fibre-coupled APD. The square wave alternating current voltage ($\pm 3 \text{ V}$) applied to the optical modulator is generated by a function generator (Agilent). The measured reflectance of the optical modulator is normalized by the reflection from the flat silver pad next to the optical modulator.

Diffraction efficiency modulation measurements. We perform the diffraction efficiency measurement of the light-field modulator using the same Nikon C2 confocal microscope as described above.

A supercontinuum laser and acousto-optic tunable filter (NKT superK) are used to generate and tune the wavelength of the laser beam ($\sim 5 \text{ nm}$ bandwidth). The laser is fibre-coupled to the microscope and illuminated on the sample by a $\times 50$ objective (Nikon, NA = 0.6). The field stop in the laser illumination path is fully closed, only leaving a 20- μm -diameter hexagonal pinhole in the field of view for signal collection. The diffracted lights from the light-field modulator are then collected by the same objective and the optical image of the Fourier plane of the light-field modulator is captured by a complementary metal–oxide–semiconductor camera (Thorlabs) with the inserted Bertrand lens. The diffraction efficiency of the light-field modulator is then extracted from the intensity integral of the diffracted spots in the optical images taken at the Fourier plane and is normalized by the reflection from the flat silver pad next to the optical modulator.

Data availability

All key data that support the findings of this study are included in the article and its Supplementary Information. Further datasets and raw measurements are available from the corresponding author on reasonable request.

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Author contributions

Q.L. and M.L.B. conceived the research idea. Q.L. built the model, performed the design and fabrication of optical modulators with input from J.v.d.G. Q.L., J.-H.S. and F.X. performed the experimental characterization of the optical modulators. A.C.J. and F.L. prepared monolayer WS_2 samples. J.H. performed wire-bonding for electrical characterization. A.D. and E.P. helped with atomic layer deposition. Y.J.L. helped with photoluminescence measurement. M.L.B. supervised the project. All of the authors contributed to writing the manuscript.

Competing interests

The authors declare no competing interests.

Additional information

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